

**Impact Factor:**

ISRA (India) = 4.971  
ISI (Dubai, UAE) = 0.829  
GIF (Australia) = 0.564  
JIF = 1.500

SIS (USA) = 0.912  
PIIHQ (Russia) = 0.126  
ESJI (KZ) = 8.997  
SJIF (Morocco) = 5.667

ICV (Poland) = 6.630  
PIF (India) = 1.940  
IBI (India) = 4.260  
OAJI (USA) = 0.350

SOI: [1.1/TAS](http://s-o-i.org/1.1/TAS) DOI: [10.15863/TAS](https://doi.org/10.15863/TAS)

International Scientific Journal  
**Theoretical & Applied Science**

p-ISSN: 2308-4944 (print) e-ISSN: 2409-0085 (online)

Year: 2020 Issue: 11 Volume: 91

Published: 18.11.2020 <http://T-Science.org>

QR – Issue



QR – Article



**M. Abbas Ghufran**

University of Kufa  
Department of Physics, Faculty of Sciences

**S. Baron Aref**

University of Kufa  
Department of Physics, Faculty of Sciences,  
Najaf, Iraq  
[arif.aljuburi@uokufa.edu.iq](mailto:arif.aljuburi@uokufa.edu.iq)

## STUDY EFFECT THE TEMPERATURE OF PREPARATION AND ANNEALING ON TiO<sub>2</sub> CHARACTERIZATIONS

**Abstract:** The characterizations of TiO<sub>2</sub> nanoparticles which prepared on FTO conductive glass bases using the hydrothermal method with different temperatures (140,160,180) for 4 h, were studied after and before annealing. The XRD patterns were appeared that the samples preparation an increase in the intensity of the peaks and a decrease in the width of the FWHM peaks was observed due to the increase in temperature as well as an increase in the grain size as the distance between the grains decreased. UV-VIS tests demonstrated optical properties, including absorption and transmission. The increase in temperature effect at the absorption edge. It was shifted towards higher energies, that is, in its preferred direction. FESEM images were showed change an increase in the density of the substance upon increasing the temperature.

**Key words:** TiO<sub>2</sub>, Hydrothermal, Nanorod, Crystallographic properties.

**Language:** English

**Citation:** Ghufran, M. A., & Aref, S. B. (2020). Study Effect the Temperature of Preparation and Annealing on TiO<sub>2</sub> Characterizations. *ISJ Theoretical & Applied Science*, 11 (91), 284-290.

**Soi:** <http://s-o-i.org/1.1/TAS-11-91-46> **Doi:**  <https://dx.doi.org/10.15863/TAS.2020.11.91.46>

**Scopus ASCC:** 3100.

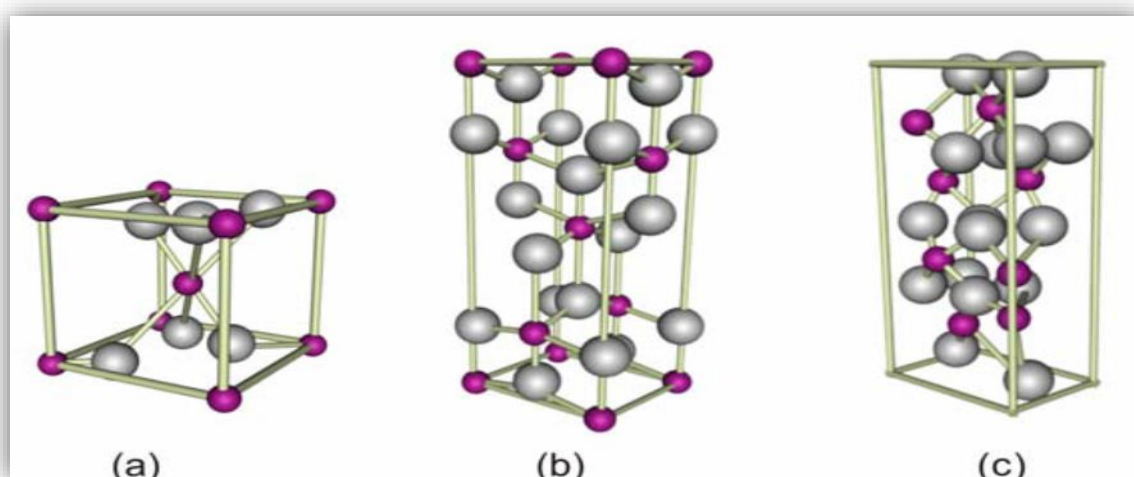
### Introduction

TiO<sub>2</sub> is one of the most common titanium compounds and is often used in many applications[1]. There are many nanostructures of titanium dioxide, including spheres, nanoparticles, and nanotubes[2].

TiO<sub>2</sub> exists in three different crystal stages: the rutile phase, the anatase phase, and the orthotic phase[3]. As in Fig. (1.1) both rutile and ananase have a (tetrahedral crystalline) structure, but they belong to different stages[4-6]

**Impact Factor:**

ISRA (India)	= 4.971	SIS (USA)	= 0.912	ICV (Poland)	= 6.630
ISI (Dubai, UAE)	= 0.829	ПИИИ (Russia)	= 0.126	PIF (India)	= 1.940
GIF (Australia)	= 0.564	ESJI (KZ)	= 8.997	IBI (India)	= 4.260
JIF	= 1.500	SJIF (Morocco)	= 5.667	OAJI (USA)	= 0.350



**Fig. (1.1):** unite (a)rutile (b)anatase (c)brookite .Grey and red spheres represent oxygen and titanium[5]

**Hydrothermal Method:** The Hydrothermal method was used for the first time by the British geological scientist Sir Rudrell [7]. This method is considered suitable for the environment because the reaction takes place in a closed system conditions, and it was defined as (any chemical reaction that is not homogeneous, either aqueous or aqueous, above room temperature at a pressure higher than the atmospheric pressure, and it takes this The method takes several hours to complete with the help of the microwave to collect a variety of oxides and hybrid materials.

## EXPERIMENTAL

### 1.Preparation of Titanium tetraizobutoxide (TTB)

Two portion of titanium(IV) chloride (BDH company) ( $TiCl_4$ ) was reacted with eight parts of butanol. Titanium (IV) chloride was put into round three neck flask. Butanol was add drop by drop with applicate of the magnetic stirrer without a heating until the end of butanol and disappeared of the fog. The oiled yellow solution was obtained

### 2. Preparation of $TiO_2$ by hydrothermal method:

In a glass container, the solution consisting of (12.5) ml of distilled water is mixed with (12.5) ml of hydrochloric acid at a concentration of (35.4%) and left for 15 minutes, then placed (0.3) ml of TTB and left for 25 minutes. Mixing is done with a magnetic stirrer in Teflon, the FTO is placed at a certain angle, and then the solution is added to cover the sample, leaving a distance from the top where this portion is conductive for the measurement. Then the autoclave container is tightly closed and placed in the oven at temperatures of (140.160.180) ° C for four hours , then the hydrothermal reactor is cooled down to room temperature. Then the samples were washed with distilled water and left to dry. Then some of the samples were annealed at a temperature of 400 ° C for half an hour. These samples classified as S1,S2,S3,S4,S5 and s6 as the table 1.1

**Table 1.1 Classification of samples Preparation**

Preparation Temperature	Before Annealing	After Annealing
140 °C	S1	S2
160 °C	S3	S4
180 °C	S5	S6

## Impact Factor:

ISRA (India) = 4.971	SIS (USA) = 0.912	ICV (Poland) = 6.630
ISI (Dubai, UAE) = 0.829	PIIHQ (Russia) = 0.126	PIF (India) = 1.940
GIF (Australia) = 0.564	ESJI (KZ) = 8.997	IBI (India) = 4.260
JIF = 1.500	SJIF (Morocco) = 5.667	OAJI (USA) = 0.350

## RESULTS AND DISCUSSION

### 1.XRD Analysis

XRD spectroscopy was used to determine the crystal size and crystal structure of titanium dioxide prepared by the hydrothermal method that is deposited on FTO conductive glass slides. The main peaks of the glass slides FTO (110) and (200) at  $2\theta=(27.5)$  and  $2\theta=(37.2)$  This corresponds to [102]

Fig. (1.2) shows the pattern of a  $TiO_2$  preparation samples S1,S2,S3,S4,S5 and S6. These were indicated that the crystal structure of these films were the anatase phase which has a clear and high crystallization nature. Diffraction peaks denote (101), (004), (200), (213) (204) anatase phase (quadrangular) at  $2\theta = (26.56), (37.91), (51.57), (61.64)$  and  $(65.61)$ . These results are in accordance with the card profile (JCPDS-04-0477).

Unit cell lattice constants ( $a=b=3.541 \text{ \AA}$ ) and ( $c=9.4836 \text{ \AA}$ ) this value are in very good

approximation to standard value ( $a=b=3.7484 \text{ \AA}$ ) and ( $c=9.5124 \text{ \AA}$ ) and this corresponds to [8,9]. By demonstrating numbers S1, S3, and S5, we refer to new peaks that increase the temperature of the composition from  $140^\circ \text{C}$  to  $160^\circ \text{C}$  and  $180^\circ \text{C}$ . Also, when comparing these samples with annealed samples S2, S4 and S6, we observe the effect of annealing on them as it will affect the change of surface shape upon annealing with a temperature of  $400^\circ \text{C}$ . The atoms will have more activation energy for diffusion, thus it will allow the lower energy atoms to move to the appropriate location in the crystal structure and thus the crystals will grow in their preferred direction and then the crystal fusion process will start to form larger granules and within the grain boundaries, the oxygen defects will decrease. An increase in temperature leads to an increase in the size of the profile and an increase in the size of the granules, and thus an increase in roughness, an increase in the intensity and a decrease in the width of FWHM also shows us an increase in the overall stress and strain due to the annealing temperature [10-12]

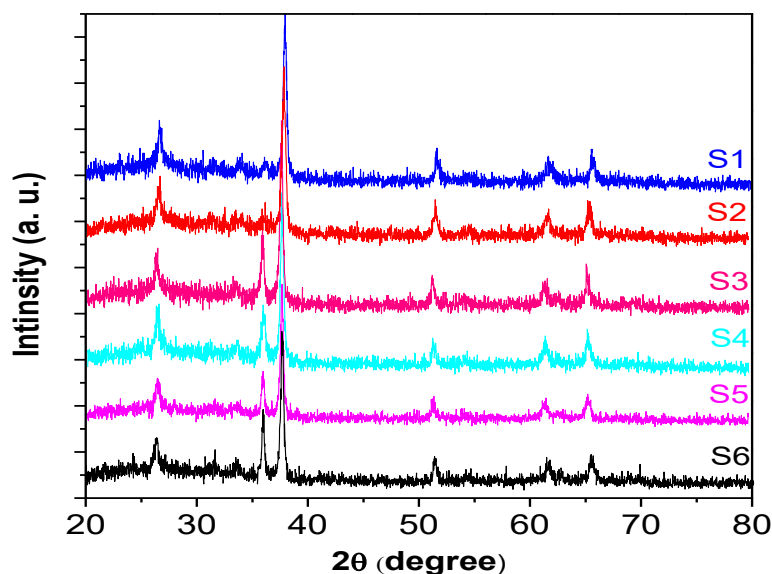


Fig. (1.2) XRD patterns for  $TiO_2$  for S1, S2, S3, S4, S5 and S6 samples

Table (1.2). Data on thin  $TiO_2$  films at different temperatures with annealing and without annealing

T(K)	Sample	D (nm)	$\delta \times 10^{-3}$ (nm <sup>-2</sup> )	$\epsilon \times 10^{-3}$
140	S1	25.22	1.57	1.37
	S2	24.2	1.7	1.43
160	S3	27.97	1.27	1.23

<b>Impact Factor:</b>	ISRA (India) = 4.971	SIS (USA) = 0.912	ICV (Poland) = 6.630
	ISI (Dubai, UAE) = 0.829	ПИИИ (Russia) = 0.126	PIF (India) = 1.940
	GIF (Australia) = 0.564	ESJI (KZ) = 8.997	IBI (India) = 4.260
	JIF = 1.500	SJIF (Morocco) = 5.667	OAJI (USA) = 0.350

	S4	24.33	1.68	1.42
180	S5	28.26	1.25	1.22
	S6	27.25	1.34	1.27

The crystal size is calculated by Scherer's equation and it is found that the average crystal size is in the range (24.2-27.25 nm) as shown in Table (1.2) as well as stress and strain were calculated, as shown in Table (1.2).

## 2. Optical Properties

The optical properties of synthesis samples were studied by UV-VIS spectroscope. These properties include the absorbance and reflectivity measurements. Depending on reflectivity, energy band gaps were calculated of the synthesis samples.

## The Absorption Measurement

Figure (1.3) shows the absorption spectrum of TiO<sub>2</sub> thin films prepared on FTO glass substrates using a different temperature hydrothermal method, with annealing and without annealing. As the absorption spectrum of S1 and S2. The absorption edge shifted from 390 nm to 400 nm. Also it has been shifted towards the red direction due to annealing and this corresponds to [15].

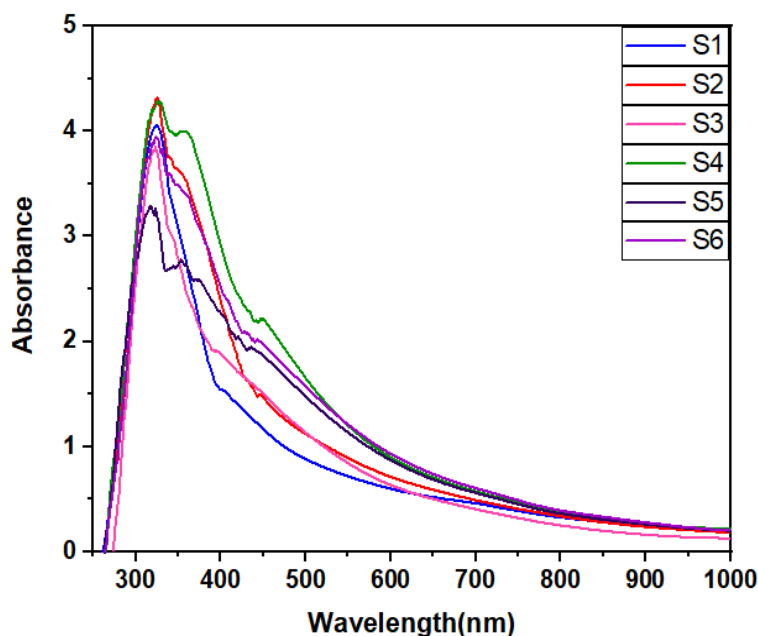


Fig. (1.3) represents the absorbance spectrum for TiO<sub>2</sub> for S1, S2, S3, S4, S5 and S6 samples

The same situation is clearly shown in the S3, S4, S5 and S6 samples shown in Fig. (1.3) where the absorption edges are slightly moved across the long wavelength (370 nm-450 nm). This is a consequence of the increase in the temperature of preparation and annealing [13,14].

### c. Transmittance (T) Measurement

Optical transmittance spectra of a thin film TiO<sub>2</sub> prepared by the hydrothermal method deposited on FTO glass substrates at different temperatures. As a

function of wavelength ranging from 390-1000 as shown in the figure (1.4), it has been observed that the permeability decreases with annealing possibly due to the decrease in the energy gap with annealing. As it showed the highest permeability at 77% and decreased to 62%. This is the reason for the effect of temperature on the surface roughness, increased grain size, and increased dislocation defects. This increases the absorption and reflection of the film

<b>Impact Factor:</b>	<b>ISRA (India) = 4.971</b>	<b>SIS (USA) = 0.912</b>	<b>ICV (Poland) = 6.630</b>
	<b>ISI (Dubai, UAE) = 0.829</b>	<b>PIIHQ (Russia) = 0.126</b>	<b>PIF (India) = 1.940</b>
	<b>GIF (Australia) = 0.564</b>	<b>ESJI (KZ) = 8.997</b>	<b>IBI (India) = 4.260</b>
	<b>JIF = 1.500</b>	<b>SJIF (Morocco) = 5.667</b>	<b>OAJI (USA) = 0.350</b>

---

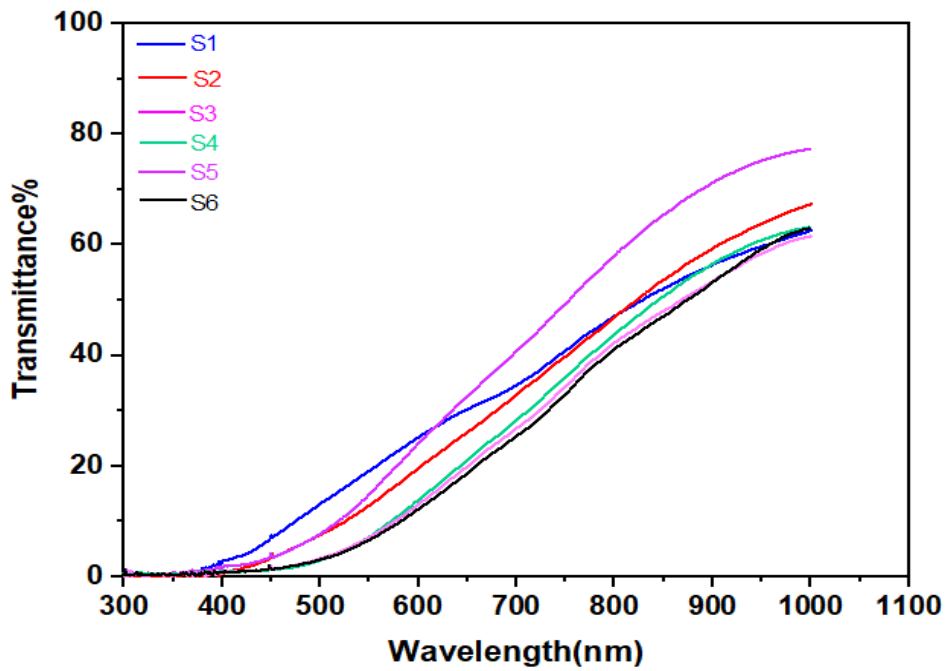


Fig. (1.4) Transmittance spectra for TiO<sub>2</sub> for S1, S2, S3, S4, S5 and S6 samples

### 3. FESEM Measurement

Figure (1.5) explain the FESEM images for TiO<sub>2</sub> samples. There was a difference between the samples in terms of density nanorod and this is due to the increase in temperature in addition to the annealing temperature and the effect of the temperature on the increase in the size of the grains and thus the surface increase significantly

## Impact Factor:

ISRA (India) = 4.971  
ISI (Dubai, UAE) = 0.829  
GIF (Australia) = 0.564  
JIF = 1.500

SIS (USA) = 0.912  
ПИИИ (Russia) = 0.126  
ESJI (KZ) = 8.997  
SJIF (Morocco) = 5.667

ICV (Poland) = 6.630  
PIF (India) = 1.940  
IBI (India) = 4.260  
OAJI (USA) = 0.350

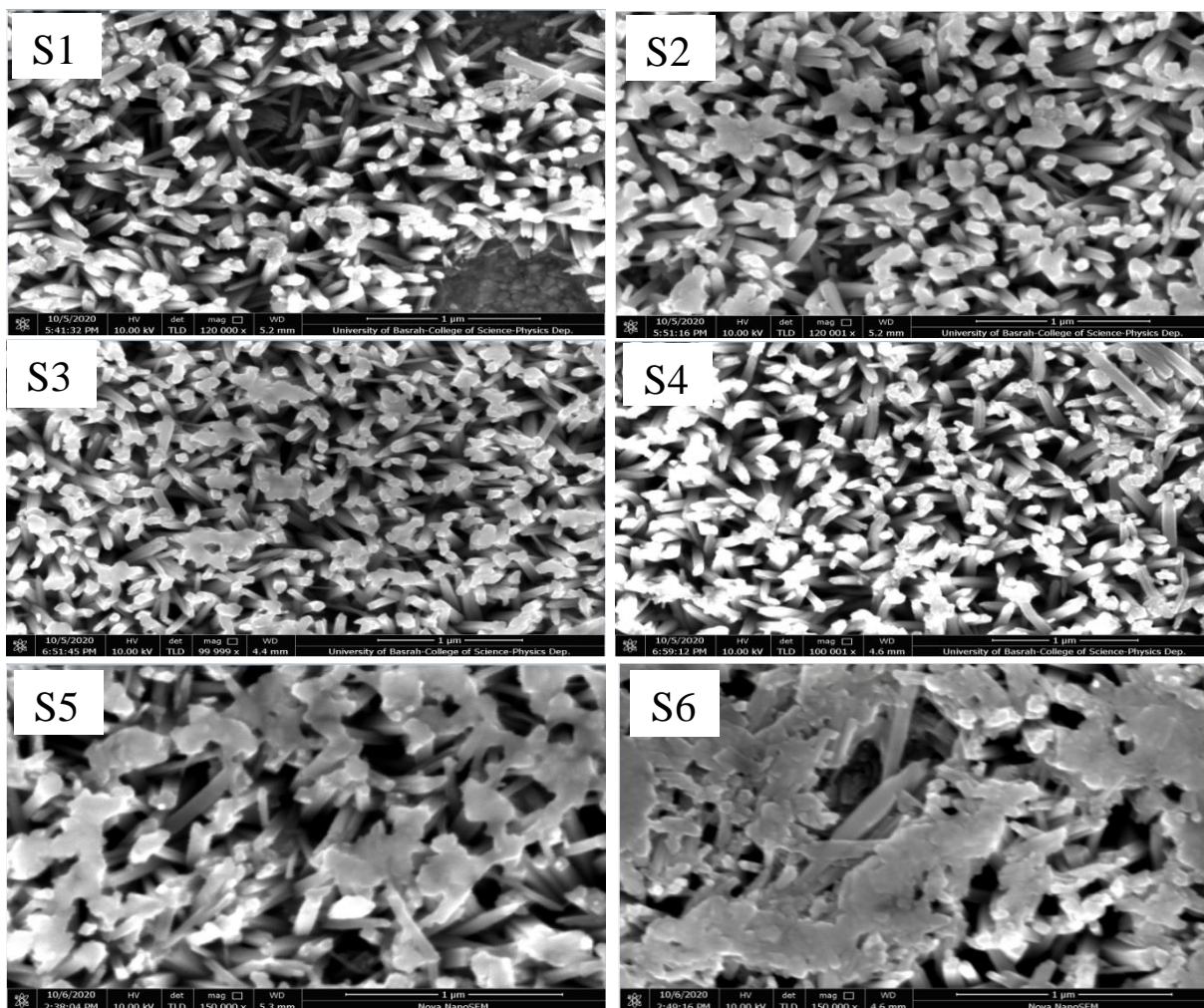


Fig. (1.5) FESEM to the TiO<sub>2</sub> samples

## Conclusion

The characterizations of TiO<sub>2</sub> nanorod were changing according to change of temperature of preparation and annealing. From the XRD diffraction pattern it can be concluded that the crystal size decreases, the distance between the crystals decreases.

While the width of FWHM decreases due to these reason. The absorption edge has been shifted towards higher energies, due to the effect of temperature as it points towards the red region. FESEM examinations showed an increase in the diffusion density of nanorod result of increasing the preparation temperature from 140° C , 160° C to 180° C .

## References:

1. Keerthana, B.G.T., et al. (2018). Hydrothermal synthesis and characterization of TiO<sub>2</sub> nanostructures prepared using different solvents. *Materials Letters*, **220**: pp. 20-23.
2. Dar, M.I., et al. (2014). *Controlled synthesis of TiO<sub>2</sub> nanoparticles and nanospheres using a microwave assisted approach for their application in dye-sensitized solar cells.*
3. Khataee, A., & Mansoori, G.A. (2011). Nanostructured titanium dioxide materials: Properties, preparation and applications. World scientific.
4. Keerthana, B.G.T., et al. (2018). Hydrothermal synthesis and characterization of TiO<sub>2</sub> nanostructures prepared using different solvents. *Materials Letters*, **220**: pp. 20-23.

**Impact Factor:**

**ISRA (India) = 4.971**  
**ISI (Dubai, UAE) = 0.829**  
**GIF (Australia) = 0.564**  
**JIF = 1.500**

**SIS (USA) = 0.912**  
**PIHII (Russia) = 0.126**  
**ESJI (KZ) = 8.997**  
**SJIF (Morocco) = 5.667**

**ICV (Poland) = 6.630**  
**PIF (India) = 1.940**  
**IBI (India) = 4.260**  
**OAJI (USA) = 0.350**

5. Seifried, S., Winterer, M., & Hahn, H. (2000). Nanocrystalline titania films and particles by chemical vapor synthesis. *Chemical Vapor Deposition*, 6(5): pp.239-2445.
6. Kalantar-zadeh, K., & Fry, B. (2008). *Nanotechnology-enabled sensors*. © Springer Science+ Business Media, LLC.
7. Byrappa, K., & Yoshimura, M. (2012). Handbook of hydrothermal technology. William Andrew.
8. Richhariya, G., & Kumar, A. (2018). Fabrication and characterization of mixed dye: Natural and synthetic organic dye. *Optical Materials*, 79: pp. 296-301.
9. Hosseini-Zori, M. (2018). Co-doped TiO<sub>2</sub> nanostructures as a strong antibacterial agent and selfcleaning cover: Synthesis, characterization and investigation of photocatalytic activity under UV irradiation. *Journal of Photochemistry and Photobiology B: Biology*, 178: pp. 512- 520.
10. Habibi, M.H., Talebian, N., & Choi, J.-H. (2007). The effect of annealing on photocatalytic properties of nanostructured titanium dioxide thin films. *Dyes and pigments*, 73(1): pp. 103110.-109.
11. Joshi, P., & Cole, M. (1999). Influence of postdeposition annealing on the enhanced structural and electrical properties of amorphous and crystalline Ta<sub>2</sub>O<sub>5</sub> thin films for dynamic random access memory applications. *Journal of Applied Physics*, 8 :2(6p. 871-880.
12. Baron, A.S. (2019). *Synthesis and Characterization of methyl ammonium lead tri halide Perovskite Compounds and their Applications in Photonic Devices*. University of Basrah.
13. Ranjitha, A., et al. (2013). Effect of annealing temperature on nanocrystalline TiO<sub>2</sub> thin films prepared by sol-gel dip coating method. *Optik*, 2013. 124(23): pp. 6201-6204. 91 References.
14. Zhao, B., et al. (2011). Effect of annealing temperature on the structure and optical properties of sputtered TiO<sub>2</sub> films. *Journal of Alloys and Compounds*, 509 :9(pp. 4060-4064.
15. Koppens, F., et al. (2014). Photodetectors based on graphene, other two-dimensional materials and hybrid systems. *Nature nanotechnology*, 9(10): pp.780-793.

<b>Impact Factor:</b>	<b>ISRA (India) = 4.971</b>	<b>SIS (USA) = 0.912</b>	<b>ICV (Poland) = 6.630</b>
	<b>ISI (Dubai, UAE) = 0.829</b>	<b>ПИИИ (Russia) = 0.126</b>	<b>PIF (India) = 1.940</b>
	<b>GIF (Australia) = 0.564</b>	<b>ESJI (KZ) = 8.997</b>	<b>IBI (India) = 4.260</b>
	<b>JIF = 1.500</b>	<b>SJIF (Morocco) = 5.667</b>	<b>OAJI (USA) = 0.350</b>

---



<b>Impact Factor:</b>	<b>ISRA (India) = 4.971</b>	<b>SIS (USA) = 0.912</b>	<b>ICV (Poland) = 6.630</b>
	<b>ISI (Dubai, UAE) = 0.829</b>	<b>ПИИИ (Russia) = 0.126</b>	<b>PIF (India) = 1.940</b>
	<b>GIF (Australia) = 0.564</b>	<b>ESJI (KZ) = 8.997</b>	<b>IBI (India) = 4.260</b>
	<b>JIF = 1.500</b>	<b>SJIF (Morocco) = 5.667</b>	<b>OAJI (USA) = 0.350</b>

---